



1/5

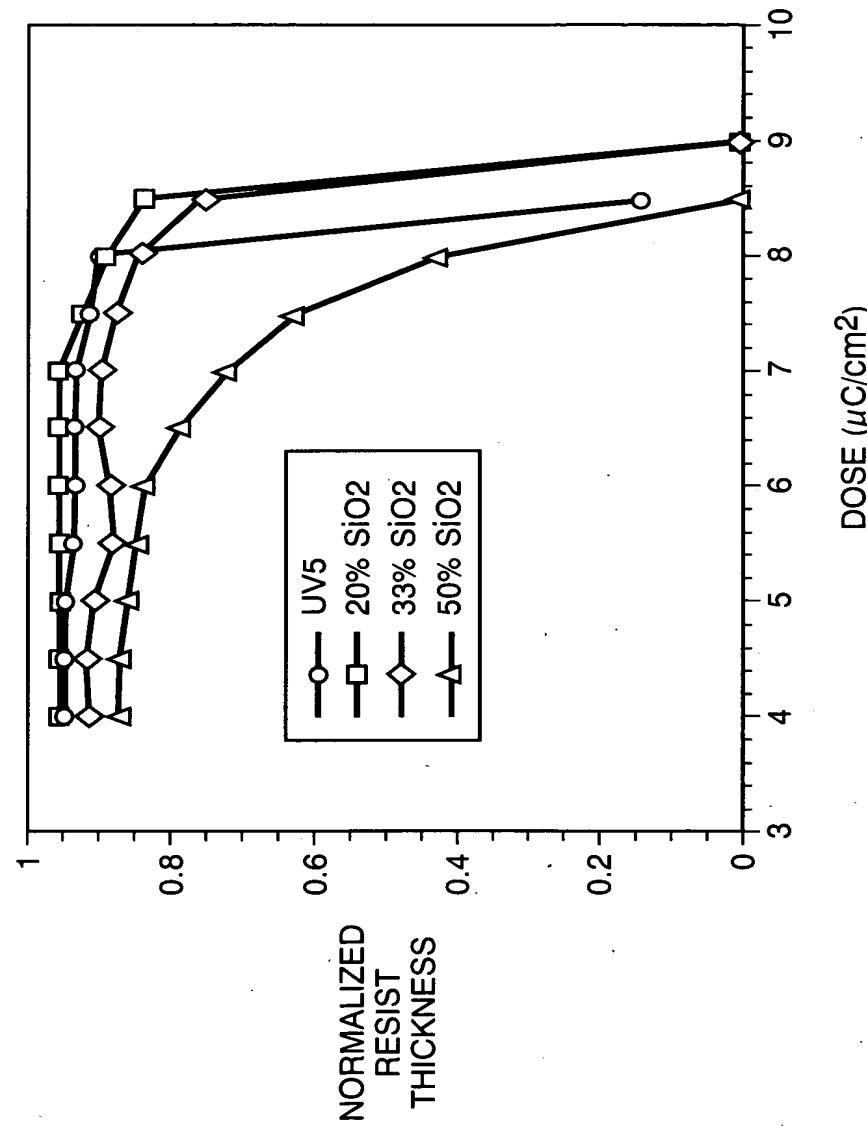
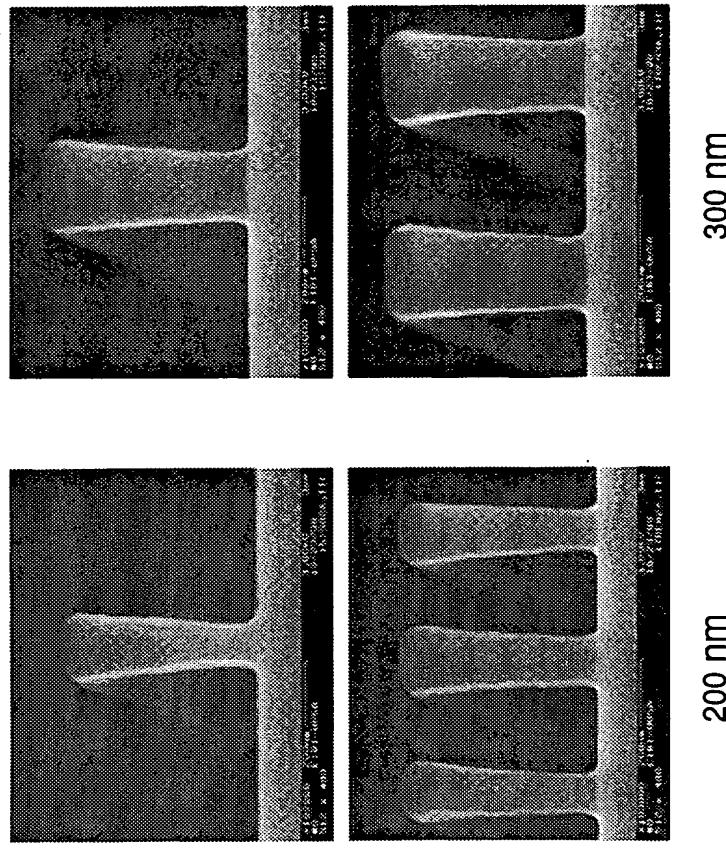


FIG. 1



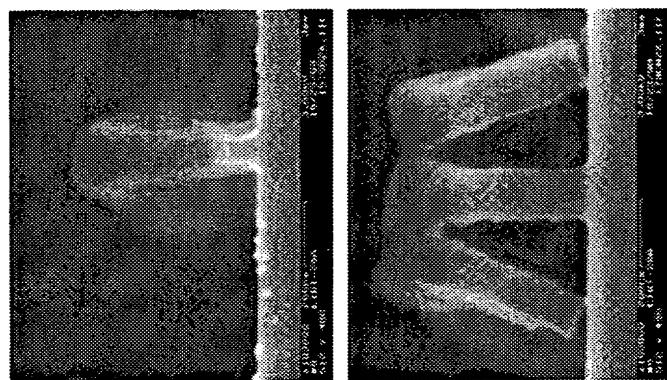
Best Available Copy

UV5 RESIST COMMERCIAL ORGANIC RESIST

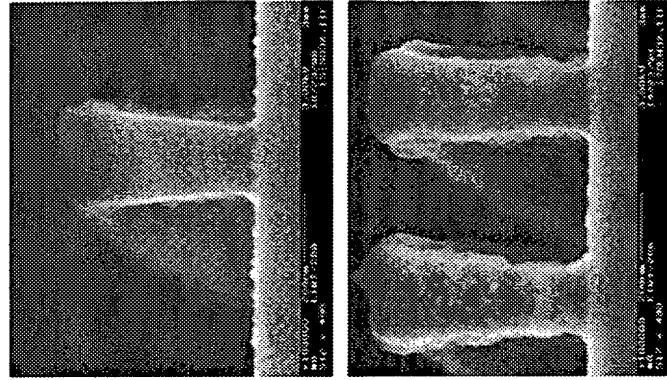


300 nm

EXPERIMENTAL 20% SiO<sub>2</sub> EIRT RESIST

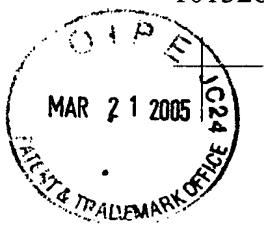


200 nm



300 nm

FIG. 2



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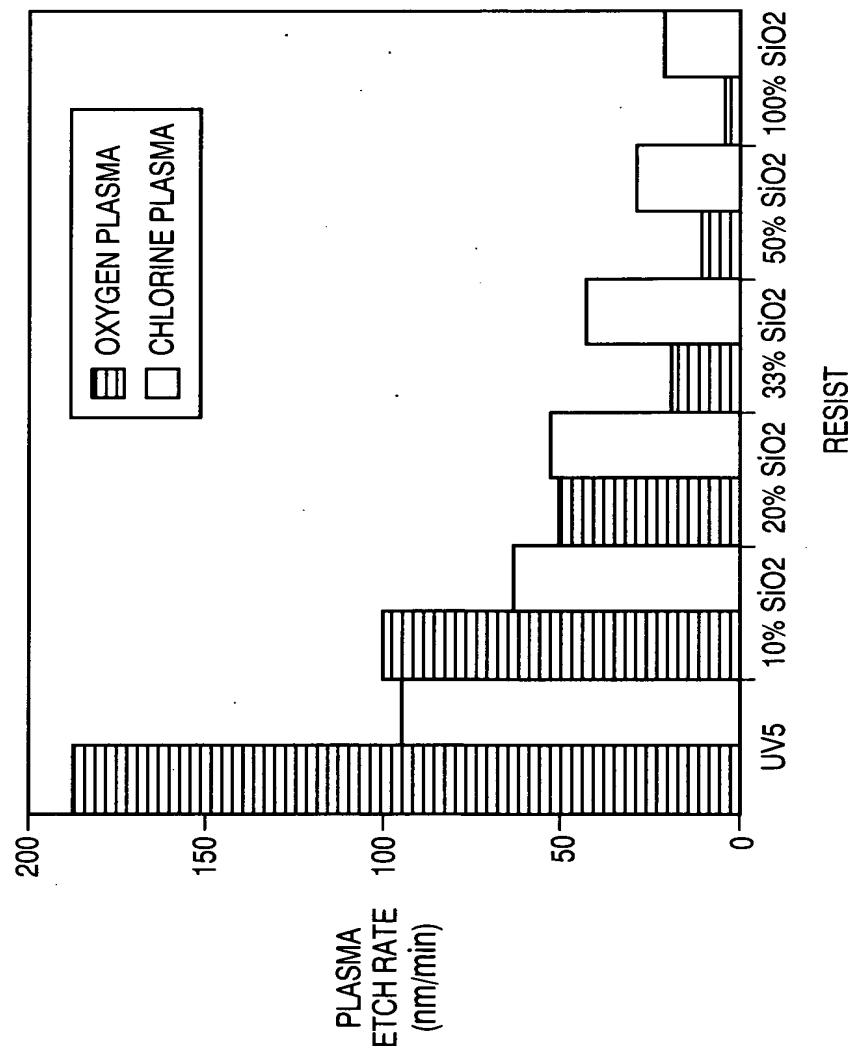


FIG. 3



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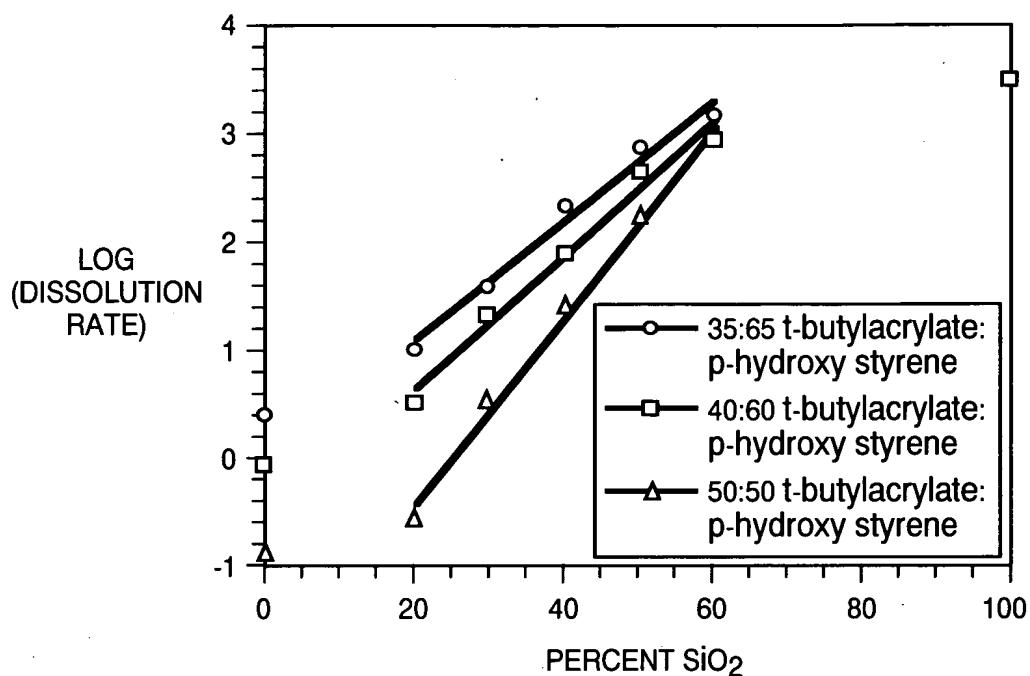


FIG. 4

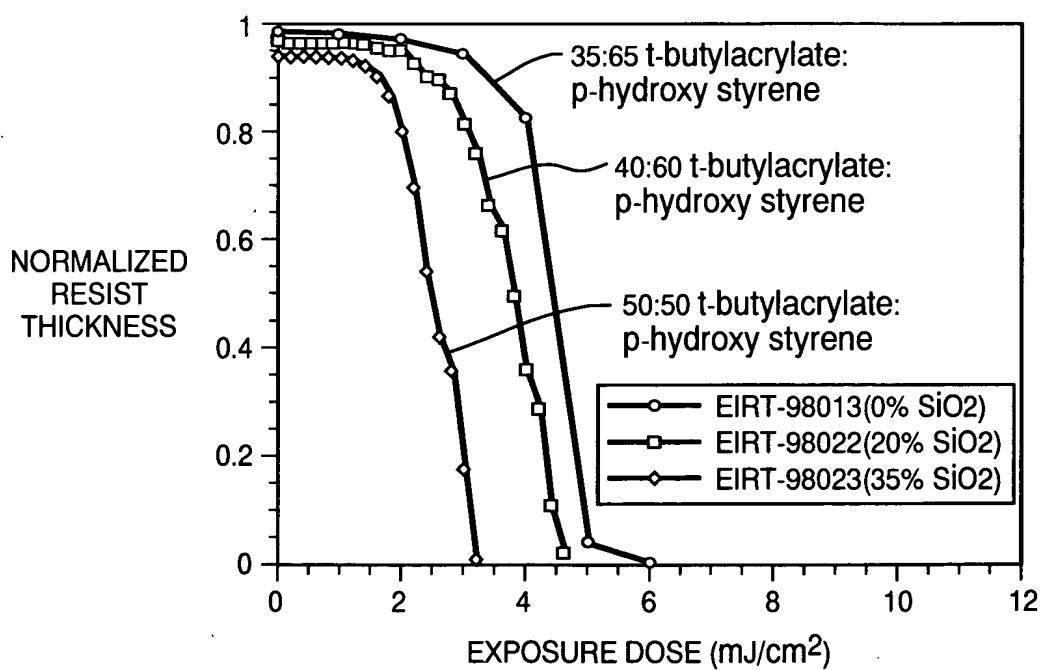
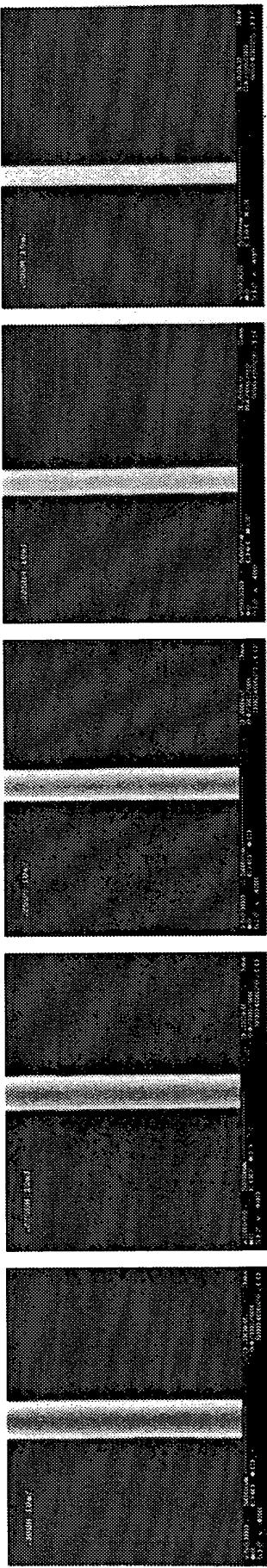
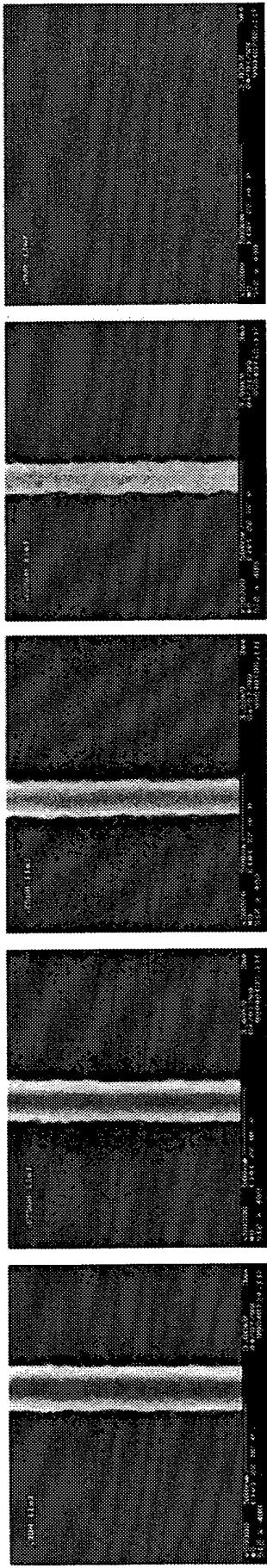


FIG. 5

EIRT 98013 RESIST (0% SiO<sub>2</sub>) PREPARED FROM 35:65 T-BUTYLACRYLATE:P-HYDROXYSTYRENEEIRT 98022 RESIST (20% SiO<sub>2</sub>) PREPARED FROM 40:60 T-BUTYLACRYLATE:P-HYDROXYSTYRENE

300 nm      275 nm      250 nm      225 nm      200 nm

FIG. 6